SEARCH REQUEST FORM

Scientific and Technical Information Center

Requester's Full Name: Art Unit: <u> 1/52</u> Mail Box and Bldg/Room I	Mkanda Walka Phone Number 30 2 70 - Location: <u>PEN 9Dol</u> R	Examiner # : <u>'756</u> <u>1337</u> Serial Number Results Format Preferred	Date: <u>16 7 204</u> : <u>16 011 88 1</u> (circle): <u>PAPER</u> : DISK E-MAIL										
If more than one search is submitted, please prioritize searches in order of need. ***********************************													
Please provide a detailed statemed Include the elected species or str	ent of the search topic, and descr actures, keywords, synonyms, a any terms that may have a specia	ribe as specifically as possible cronyms, and fegistry number all meaning. Give examples o	e the subject matter to be searched. ers, and combine with the concept or r relevant citations, authors, etc, if										
Title of Invention: 236	Sixet Alloched												
Inventors (please provide full	names):												
Earliest Priority Filing Date	e:												
For Sequence Searches Only Pl appropriate serial number.	ease include all pertinent informat	ion (parent, child, divisional, o	r issued patent numbers) along with the										
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STAFF USE ONLY	Type of Search	4=	d cost where applicable										
Searcher: Ed	NA Sequence (#)	STN P	50										
Searcher Phone #:		(2)											
Searcher Location:	Structure (#)	Questel/Orbit											
Date Searcher Picked Up:													
Date Completed: $6-8-04$													
Searcher Prep & Review Time:	Fulltext												
Clorical Prep Time. Online Time: 55	Patent Family Other	Other (specify)											

PTO-1590 (8-01)

=> file reg FILE 'REGISTRY' ENTERED AT 16:56:50 ON 08 JUN 2004 USE IS SUBJECT TO THE TERMS OF YOUR STN CUSTOMER AGREEMENT. PLEASE SEE "HELP USAGETERMS" FOR DETAILS. COPYRIGHT (C) 2004 American Chemical Society (ACS)

=> d his

FILE 'BEILSTEIN' ENTERED AT 16:47:40 ON 08 JUN 2004 L1 STR

FILE 'REGISTRY' ENTERED AT 16:54:56 ON 08 JUN 2004

L2 SCR 2043

L3 1 S L1 AND L2

L4 13 S L1 AND L2 FUL SAV L4 WAL881/A

FILE 'CAOLD' ENTERED AT 16:56:33 ON 08 JUN 2004 L5 0 S L4

FILE 'ZCAPLUS' ENTERED AT 16:56:39 ON 08 JUN 2004 L6 4 S L4

FILE 'REGISTRY' ENTERED AT 16:56:50 ON 08 JUN 2004

=> d 14 que stat L1 STR

NODE ATTRIBUTES: CONNECT IS E1 RC AT 8 DEFAULT MLEVEL IS ATOM GGCAT IS SAT AT 8 DEFAULT ECLEVEL IS LIMITED ECOUNT IS M1-X4 C AT

GRAPH ATTRIBUTES:

RING(S) ARE ISOLATED OR EMBEDDED

NUMBER OF NODES IS 11

STEREO ATTRIBUTES: NONE T₁2 SCR 2043

L413 SEA FILE=REGISTRY SSS FUL L1 AND L2

100.0% PROCESSED 41991 ITERATIONS

SEARCH TIME: 00.00.01

13 ANSWERS

=> file zcaplus

FILE 'ZCAPLUS' ENTERED AT 16:57:03 ON 08 JUN 2004 USE IS SUBJECT TO THE TERMS OF YOUR STN CUSTOMER AGREEMENT. PLEASE SEE "HELP USAGETERMS" FOR DETAILS. COPYRIGHT (C) 2004 AMERICAN CHEMICAL SOCIETY (ACS)

=> d 16 1-4 ibib abs hitstr hitrn

ANSWER 1 OF 4 ZCAPLUS COPYRIGHT 2004 ACS on STN L6

ACCESSION NUMBER: 2004:198611 ZCAPLUS

140:236543 DOCUMENT NUMBER:

TITLE: Polymer compositions with good storage stability

Hotta, Iwao; Kodama, Aya; Murata, Shigeru Kyowa Oil and Fat Co., Ltd., Japan INVENTOR(S):

PATENT ASSIGNEE(S):

Jpn. Kokai Tokkyo Koho, 15 pp. SOURCE:

CODEN: JKXXAF

DOCUMENT TYPE:

Patent LANGUAGE: Japanese

FAMILY ACC. NUM. COUNT: 1

PATENT INFORMATION:

PATENT NO. KIND DATE APPLICATION NO. DATE ______ JP 2004075864 A2 20040311 JP 2002-238/12 20020820 JP 2002-238712 packaging ______ PRIORITY APPLN. INFO.: The compns., useful for coating, adhesives, electronic packaging AΒ materials, etc., contain compds. bearing CO2CH(OR3)CHR1R2 (R1-R3 = alkyl, aryl, aralkyl; R1 and R2 may form cycloalkyl groups with vicinal C atom; R2 and R3 may form O-contg. heterocyclic groups with vicinal CCO) and compds. bearing functional groups reactive with carboxyl groups. Thus, a compn. contg. 1-propoxy-2-methylpropyl methacrylate (manufd. from methacrylic acid and 1-propoxy-2-methylpropene)-styrene-Bu acrylate-Bu methacrylate copolymer, Epikote 1001 (epoxy resin), and bis(2-ethylhexyl)sulfosuccinic acid N-methylmorpholine salt showed viscosity increase 2% after storage at 50° for 1 mo.

IT 666817-41-0P

(vinyl polymer compns. with good storage stability)

RN 666817-41-0 ZCAPLUS

CN 2-Propenoic acid, 2-methyl-, butyl ester, polymer with butyl 2-propenoate, ethenylbenzene and 2-methyl-1-propoxypropyl 2-methyl-2-propenoate (9CI) (CA INDEX NAME)

CM 1

CRN 487048-11-3 CMF C11 H20 O3

CM 2

CRN 141-32-2 CMF C7 H12 O2

CM 3

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

CRN 97-88-1 CMF C8 H14 O2

 $\begin{array}{c|c} O & CH_2 \\ \parallel & \parallel \\ n\text{-BuO-}C\text{--}C\text{--Me} \end{array}$

IT 666817-41-0P

(vinyl polymer compns. with good storage stability)

L6 ANSWER 2 OF 4 ZCAPLUS COPYRIGHT 2004 ACS on STN

ACCESSION NUMBER: 2004:183137 ZCAPLUS

DOCUMENT NUMBER:

140:225805

TITLE:

Composition sensitive to visible light Yamaoka, Tsuguo; Ito, Katsuhiro; Iwasaki,

INVENTOR(S): Yamaoka, Tsuguo; Ito, K.
Tsuyoshi; Shimizu, Ikuo

PATENT ASSIGNEE(S):

Kyowa Yuka Co., Ltd., Japan

COLIDGE.

PCT Int. Appl., 16 pp.

SOURCE:

CODEN: PIXXD2

DOCUMENT TYPE:

Patent Japanese

LANGUAGE:

FAMILY ACC. NUM. COUNT:

PATENT INFORMATION:

PATENT	PATENT NO.		KIND DATE			APPLICATION NO.				Э.	DATE				
WO 2004019131		A1 20040304			WO 2003-JP105				34 20030820						
W:	ΑE,	AG,	AL,	AM,	AT,	AU,	ΑZ,	BA,	BB,	BG,	BR,	BY,	BZ,	CA,	CH,
	CN,	CO,	CR,	CU,	CZ,	DE,	DK,	DM,	DZ,	EC,	EE,	ES,	FI,	GB,	GD,
	GE,	GH,	GM,	HR,	HU,	ID,	IL,	IN,	IS,	JP,	KΕ,	KG,	KR,	KΖ,	LC,
	LK,	LR,	LS,	LT,	LU,	LV,	MA,	ΜŲ,	MG,	MK,	MN,	MW,	MX,	MZ,	NI,
	NO,	NZ,	OM,	PG,	PH,	PL,	PT,	RO,	RU,	SC,	SD,	SE,	SG,	SK,	SL,
	SY,	ТJ,	TM,	TN,	TR,	TT,	TZ,	UA,	UG,	US,	UZ,	VC,	VN,	YU,	ZA,
	ZM,	ZW,	AM,	AZ,	BY,	KG,	KΖ,	MD,	RU,	TJ					
RW	: GH,	GM,	KE,	LS,	MW,	ΜZ,	SD,	SL,	SZ,	TZ,	UG,	ZM,	ZW,	AT,	BE,
	BG,	CH,	CY,	CZ,	DE,	DK,	EE,	ES,	FI,	FR,	GB,	GR,	HU,	ΙE,	ΙΤ,
	LU,	MC,	NL,	PT,	RO,	SE,	SI,	SK,	TR,	BF,	ΒJ,	CF,	CG,	CI,	CM,
	GΑ,	GN,	GQ,	GW,	ML,	MR,	NE,	SN,	TD,	ΤG					
PRIORITY APPLN. INFO.: JP 2002-238714 A 20020820															

$$\begin{bmatrix} R^4 \\ 0 \\ 0 \\ R^1 \\ R^3 \\ R^2 \end{bmatrix}$$

Ι

The invention relates to a compn. highly sensitive to visible light which comprises: (a) a polymer having repeating units of a structure represented by the general formula I (wherein R1, R2, and R3 are the same or different and each represents (un) substituted alkyl, (un) substituted aryl, or (un) substituted aralkyl, provided that R1 and R2 may form cycloalkyl in cooperation with the adjacent carbon atom; and R4 represents lower alkyl); (b) a compd. which generates an acid upon irradn. with visible light; and (c) a sensitizing dye. The compn. is useful as a material for forming electronic circuits, lithog. printing material, color filters, etc.

IT 487048-19-1P 666706-27-0P

(compn. sensitive to visible light)

RN 487048-19-1 ZCAPLUS

CN 2-Propenoic acid, 2-methyl-, methyl ester, polymer with 2-methyl-1-propoxypropyl 2-methyl-2-propenoate (9CI) (CA INDEX NAME)

CM 1

CRN 487048-11-3 CMF C11 H20 O3

CM 2

CRN 80-62-6 CMF C5 H8 O2

RN 666706-27-0 ZCAPLUS

CN 2-Propenoic acid, 2-methyl-, 2-hydroxyethyl ester, polymer with 1-methoxy-2-methylpropyl 2-methyl-2-propenoate and methyl 2-methyl-2-propenoate (9CI) (CA INDEX NAME)

CM 1

CRN 487048-12-4 CMF C9 H16 O3

CM 2

CRN 868-77-9 CMF C6 H10 O3

$$^{
m H_2C}$$
 O $^{
m H_2H_2C}$ $^{
m Me-C-C-C-O-CH_2-CH_2-OH}$

CM 3

CRN 80-62-6 CMF C5 H8 O2

IT 487048-19-1P 666706-27-0P

(compn. sensitive to visible light)

REFERENCE COUNT:

4 THERE ARE 4 CITED REFERENCES AVAILABLE FOR THIS RECORD. ALL CITATIONS AVAILABLE IN

Syouth

THE RE FORMAT

L6 ANSWER 3 OF 4 ZCAPLUS COPYRIGHT 2004 ACS on STN

ACCESSION NUMBER:

2004:17489 ZCAPLUS

DOCUMENT NUMBER:

140:84633

TITLE:

Positive-working photoresist composition and

patterning process using the same

INVENTOR(S):

Takeda, Takanobu; Watanabe, Osamu Shin-Etsu Chemical Co., Ltd., Japan

PATENT ASSIGNEE(S): SOURCE:

Eur. Pat. Appl., 24 pp.

CODEN: EPXXDW

DOCUMENT TYPE:

Patent

LANGUAGE:

English

FAMILY ACC. NUM. COUNT: 1

PATENT INFORMATION:

PATENT NO. KIND DATE APPLICATION NO. DATE

EP 1378795 A1 20040107 EP 2003-254243 20030703 R: AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC,

PT, IE, SI, LT, LV, FI, RO, MK, CY, AL, TR, BG, CZ, EE, HU, SK

JP 2004045448 A2 20040212 US 2004023153 A1 20040205 JP 2002-195740 20020704 US 2003-611881 20030703

PRIORITY APPLN. INFO.:

JP 2002-195740 A 20020704

AB The invention relates to resist compns. comprising as the base resin a polymer using an alkoxyalkyl (meth)acrylate as a reactive group which is decomposable under the action of an acid to increase soly. in alkali have advantages including a practical level of shelf stability, a significantly enhanced contrast of alkali dissoln. rate before and after exposure, a high sensitivity, and a high resoln. over a wide baking temp. range. The compns. are best suited as a chem. amplified pos. resist material for micro-patterning in the manuf. of VLSI.

IT 640291-47-0DP, hydrolyzed 640291-48-1DP,

hydrolyzed 640291-49-2DP, hydrolyzed 640291-50-5DP

, hydrolyzed 640291-51-6DP, hydrolyzed

640291-52-7DP, hydrolyzed

(alkoxyalkyl (meth) acrylate polymer in resist compn.)

RN 640291-47-0 ZCAPLUS

CN 2-Propenoic acid, 2-methyl-, 1-methoxy-2-methylpropyl ester, polymer with ethenylbenzene and 4-ethenylphenyl acetate (9CI) (CA INDEX NAME)

CRN 487048-12-4 CMF C9 H16 O3

CM 2

CRN 2628-16-2 CMF C10 H10 O2

CM 3

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

RN 640291-48-1 ZCAPLUS

CN 2-Propenoic acid, 2-methyl-, 1-ethoxy-2-methylpropyl ester, polymer with ethenylbenzene and 4-ethenylphenyl acetate (9CI) (CA INDEX NAME)

CM 1

CRN 487048-13-5 CMF C10 H18 O3

CRN 2628-16-2 CMF C10 H10 O2

CM 3

CRN 100-42-5 CMF C8 H8

$$H_2C = CH - Ph$$

RN 640291-49-2 ZCAPLUS

CN 2-Propenoic acid, 2-methyl-, 1-methoxy-2-methylpropyl ester, polymer with 1-(1,1-dimethylethoxy)-4-ethenylbenzene and 4-ethenylphenyl acetate (9CI) (CA INDEX NAME)

CM 1

CRN 487048-12-4 CMF C9 H16 O3

$$\begin{array}{c|c} \text{H}_2\text{C} & \text{O} & \text{OMe} \\ \parallel & \parallel & \parallel \\ \text{Me-C-C-O-CH-Pr-i} \end{array}$$

CM 2

CRN 95418-58-9 CMF C12 H16 O

CM 3

CRN 2628-16-2 CMF C10 H10 O2

RN 640291-50-5 ZCAPLUS

CN 2-Propenoic acid, 2-methyl-, 1-methoxy-2-methylpropyl ester, polymer with 1-(1,1-dimethylpropoxy)-4-ethenylbenzene and 4-ethenylphenyl acetate (9CI) (CA INDEX NAME)

CM 1

CRN 487048-12-4 CMF C9 H16 O3

$$\begin{array}{c|c} ^{H_2C} & \text{O} & \text{OMe} \\ \parallel & \parallel & \parallel \\ \text{Me-C-C-O-CH-Pr-i} \end{array}$$

CM 2

CRN 146716-59-8 CMF C13 H18 O

CRN 2628-16-2 CMF C10 H10 O2

RN 640291-51-6 ZCAPLUS

CN 2-Propenoic acid, 2-methyl-, 2-ethyltricyclo[3.3.1.13,7]dec-2-yl ester, polymer with 4-ethenylphenyl acetate and 1-methoxy-2-methylpropyl 2-methyl-2-propenoate (9CI) (CA INDEX NAME)

CM 1

CRN 487048-12-4 CMF C9 H16 O3

$$\begin{array}{c|c} ^{H_2C} & \text{O} & \text{OMe} \\ \parallel & \parallel & \parallel \\ \text{Me-} & \text{C-} & \text{C-} & \text{O-} & \text{CH-} & \text{Pr-i} \end{array}$$

CM 2

CRN 209982-56-9 CMF C16 H24 O2

CRN 2628-16-2 CMF C10 H10 O2

RN 640291-52-7 ZCAPLUS

CN 2-Propenoic acid, 2-methyl-, 1-methoxy-2-methylpropyl ester, polymer with 4-ethenylphenyl acetate and 2-methyltricyclo[3.3.1.13,7]dec-2-yl 2-methyl-2-propenoate (9CI) (CA INDEX NAME)

CM 1

CRN 487048-12-4 CMF C9 H16 O3

CM 2

CRN 177080-67-0 CMF C15 H22 O2

CRN 2628-16-2 CMF C10 H10 O2

IT 640291-47-0DP, hydrolyzed 640291-48-1DP, hydrolyzed 640291-49-2DP, hydrolyzed 640291-50-5DP, hydrolyzed 640291-51-6DP, hydrolyzed 640291-52-7DP, hydrolyzed

(alkoxyalkyl (meth)acrylate polymer in resist compn.)

REFERENCE COUNT:

THERE ARE 4 CITED REFERENCES AVAILABLE FOR THIS RECORD. ALL CITATIONS AVAILABLE IN

THE RE FORMAT

L6 ANSWER 4 OF 4 ZCAPLUS COPYRIGHT 2004 ACS on STN

4

ACCESSION NUMBER:

2003:58035 ZCAPLUS

DOCUMENT NUMBER:

138:108656

TITLE:

Preparation of ethers by reacting hydroxy- or carboxy-containing compounds with alkenyl ethers

Shimizu Thuo: The Katsubiro: Ocada Kazuwagu:

INVENTOR(S):

Shimizu, Ikuo; Ito, Katsuhiro; Osada, Kazuyasu;

Yamaoka, Tsuguo

PATENT ASSIGNEE(S):

Kyowa Yuka Co., Ltd., Japan

SOURCE:

PCT Int. Appl., 32 pp.

CODEN: PIXXD2

DOCUMENT TYPE:

Patent

LANGUAGE:

Japanese

FAMILY ACC. NUM. COUNT:

PATENT INFORMATION:

PATENT NO.

KIND DATE

APPLICATION NO. DATE

```
/ A1
     WO 2003006407
                            20030123
                                           WO 2002-JP7117
                                                            20020712
       W: AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BY, BZ, CA, CH,
             CN, CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, ES, FI, GB, GD,
             GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KR, KZ, LC,
             LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NO,
             NZ, OM, PH, PL, PT, RO, RU, SD, SE, SG, SI, SK, SL, TJ, TM,
             TN, TR, TT, TZ, UA, UG, US, UZ, VN, YU, ZA, ZM, ZW, AM, AZ,
             BY, KG, KZ, MD, RU, TJ, TM
         RW: GH, GM, KE, LS, MW, MZ, SD, SL, SZ, TZ, UG, ZM, ZW, AT, BE,
             BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, IE, IT, LU,
             MC, NL, PT, SE, SK, TR, BF, BJ, CF, CG, CI, CM, GA, GN, GQ,
             GW, ML, MR, NE, SN, TD, TG
     EP 1415968
                       A1
                            20040506
                                           EP 2002-746017
                                                            20020712
             AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC,
             PT, IE, SI, LT, LV, FI, RO, MK, CY, AL, TR, BG, CZ, EE, SK
PRIORITY APPLN. INFO.:
                                        JP 2001-213246
                                                         A 20010713
                                        WO 2002-JP7117
                                                         W 20020712
AB
     The ether compd. is prepd. by reacting an alkenyl ether
     R1(R2)C:CHOR3 with an hydroxy- or carboxy-contg. compd.
     -O(R30) CHCH(R2)R1 (R1, R2, R3 = (un) substituted alkyl, aryl and
     aralkyl or R1 + R2 = cycloalkyl). The ether compds. are useful in
     resist compns. and coating compns. and as intermediates for
    medicines. Thus, 10.0 parts 1-propoxy-2-methylpropyl obtained from
    methacrylic acid and 1-propoxy-2-methylpropene was polymd. in the
    presence of AIBN at 70° for 5 h to give a 7.9 parts
    homopolymer with no. av. mol. wt. 9682 and mol. wt. distribution
    2.2.
    487048-15-7P 487048-16-8P 487048-17-9P
ΙT
    487048-18-0P 487048-19-1P
        (prepn. of 'ethers by reacting hydroxy- or carboxy-contg. compds.
        with alkenyl ethers)
     487048-15-7 ZCAPLUS
RN
CN
    2-Propenoic acid, 2-methyl-, 2-methyl-1-propoxypropyl ester,
    homopolymer (9CI) (CA INDEX NAME)
    CM
          1
    CRN
          487048-11-3
    CMF
          C11 H20 O3
```

RN 487048-16-8 ZCAPLUS

CN 2-Propenoic acid, 2-methyl-, 1-methoxy-2-methylpropyl ester, homopolymer (9CI) (CA INDEX NAME)

CM 1

CRN 487048-12-4 CMF C9 H16 O3

RN 487048-17-9 ZCAPLUS

CN 2-Propenoic acid, 2-methyl-, 1-ethoxy-2-methylpropyl ester, homopolymer (9CI) (CA INDEX NAME)

CM 1

CRN 487048-13-5 CMF C10 H18 O3

RN 487048-18-0 ZCAPLUS

CN 2-Propenoic acid, 2-methyl-, 1-ethoxy-2-ethylbutyl ester, homopolymer (9CI) (CA INDEX NAME)

CM 1

CRN 487048-14-6 CMF C12 H22 O3

$$\begin{array}{c|cccc} {\rm H_2C} & {\rm O} & {\rm OEt} \\ & & || & || & | \\ {\rm Me-C-C-O-CH-CHEt_2} \end{array}$$

RN 487048-19-1 ZCAPLUS

CN 2-Propenoic acid, 2-methyl-, methyl ester, polymer with 2-methyl-1-propoxypropyl 2-methyl-2-propenoate (9CI) (CA INDEX NAME)

CRN 487048-11-3 CMF C11 H20 O3

CM 2

CRN 80-62-6 CMF C5 H8 O2

IT 487048-15-7P 487048-16-8P 487048-17-9P 487048-18-0P 487048-19-1P

1

(prepn. of ethers by reacting hydroxy- or carboxy-contg. compds. with alkenyl ethers)

REFERENCE COUNT:

THERE ARE 1 CITED REFERENCES AVAILABLE FOR THIS RECORD. ALL CITATIONS AVAILABLE IN THE RE FORMAT